Notice of Allowability	Application No.	Applicant(s)		
	09/536,037	LIETAL	LI ET AL.	
	Examiner	Art Unit		
	Toniae M. Thomas	2822		
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate communication is search MPEP 1308.	n this application. If not included unication will be mailed in due cour	Se THIS	
1. X This communication is responsive to the RCE filed on 11 M	<u>flay 2005.</u>			
2. ☑ The allowed claim(s) is/are <u>52-64</u> .				
3. \boxtimes The drawings filed on <u>27 March 2000</u> are accepted by the i	Examiner.			
4. Acknowledgment is made of a claim for foreign priority un a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	been received. been received in Application currents have been received of this communication to file	n No I in this national stage application f		
5. A SUBSTITUTE OATH OR DECLARATION must be submi INFORMAL PATENT APPLICATION (PTO-152) which give	tted. Note the attached EXA s reason(s) why the oath or	MINER'S AMENDMENT or NOTIC declaration is deficient.	E OF	
6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftsperso 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.6 each sheet. Replacement sheet(s) should be labeled as such in the	on's Patent Drawing Review Amendment / Comment or B4(c)) should be written on the header according to 37 CFI	in the Office action of e drawings in the front (not the back R 1.121(d).		
 DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F 	it of BIOLOGICAL MATE FOR THE DEPOSIT OF BIO	RIAL must be submitted. Note to LOGICAL MATERIAL.	he	
Attachment(s) I. ☑ Notice of References Cited (PTO-892)	e El Nation de la	15 / // " " " " " " " " " " " " " " " " "		
2. ☐ Notice of Braftperson's Patent Drawing Review (PTO-948)	6. 🔲 Interview Su	ormal Patent Application (PTO-152 mmary (PTO-413),)	
 Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date 05/11/05; 10/03/05 □ Examiner's Comment Regarding Requirement for Deposit 	3), 7. Examiner's A	Mail Date Amendment/Comment Statement of Reasons for Allowanc	· o	
of Biological Material	9. Other		C	
		Mary Wilczewski Primary Examine	r	

EXAMINER'S AMENDMENT

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after allowance or after an Office action under *Ex Parte Quayle*, 25 USPQ 74, 453 O.G. 213 (Comm'r Pat. 1935). Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submissions filed on 11 May 2005 and 03 October 2005 have been entered.

Reasons for Allowance

2. The following is an examiner's statement of reasons for allowance: the newly submitted and newly cited prior art of record does not anticipate, teach, or suggest a method for forming a low k inter-level dielectric layer substantially as claimed, wherein the method comprises forming a dielectric layer comprising a compound of silicon bonded to both nitrogen and an organic material, and subsequently exposing the dielectric layer to a plasma comprising nitrogen – the nitrogen-comprising plasma effective to reduce the dielectric constant to below what it was prior to the step of exposing.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should

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preferably accompany the issue fee. Such submissions should be clearly

labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Toniae M. Thomas whose telephone number is (571) 272-1846. The examiner can normally be reached on Monday through Friday from 8:30 a.m. to 5:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith can be reached on (571) 272-2429. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TMT 11 December 2005

> Mary Wilczewski Primary Examiner

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